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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. | |
|---------------------------|-------------------|----------------------|------------------------|------------------|--|
| 10/749,489 | 12/30/2003 | Seung Hee Jwa | 20063/10020 | 20063/10020 1201 | |
| 34431 7. | 590 02/16/2005 | EXAM | EXAMINER | | |
| | LIGHT & ZIMMERMAN | LEE, C. | LEE, CALVIN | | |
| 20 N. WACKE SUITE 4220 | R DRIVE | ART UNIT | PAPER NUMBER | | |
| CHICAGO, IL 60606 | | | 2818 | | |
| | | | DATE MAILED: 02/16/200 | 5 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | | Application | n No | Applicant(s) | | | | |
|---|---|--|---|--|---------------------|--|--|--|
| Office Action Summary | | 10/749,48 | | JWA, SEUNG HEE | | | | |
| | | Examiner | | Art Unit | | | | |
| | | Lee, Calvi | n | 2818 | | | | |
| | MAILING DATE of this commun | | | orrespondence ad | dress | | | |
| Period for Re | • | | | 0. 5001 | | | | |
| THE MAIL - Extensions of after SIX (6) - If the period - If NO period - Failure to re Any reply re | ENED STATUTORY PERIOD F ING DATE OF THIS COMMUN of time may be available under the provisions MONTHS from the mailing date of this come for reply specified above is less than thirty (if for reply is specified above, the maximum sply within the set or extended period for reply ceived by the Office later than three months in term adjustment. See 37 CFR 1.704(b). | IICATION. s of 37 CFR 1.136(a). In no eventual munication. 30) days, a reply within the state tatutory period will apply and will will by statute. cause the app | ent, however, may a reply be tim story minimum of thirty (30) days Il expire SIX (6) MONTHS from ication to become ABANDONE! | nely filed s will be considered timely the mailing date of this co D (35 U.S.C. § 133). | y. ommunication. | | | |
| Status | | | | | | | | |
| 1)∏ Resi | consive to communication(s) file | ed on | | | | | | |
| <i>,</i> — . | This action is FINAL . 2b)⊠ This action is non-final. | | | | | | | |
| <i>'</i> — | Since this application is in condition for allowance except for formal matters, prosecution as to the merits is | | | | | | | |
| close | closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. | | | | | | | |
| Disposition o | f Claims | | | | | | | |
| 4)⊠ Claiı | ☑ Claim(s) <u>1-8</u> is/are pending in the application. | | | | | | | |
| • | 4a) Of the above claim(s) is/are withdrawn from consideration. | | | | | | | |
| 5)⊠ Claiı | ☐ Claim(s) <u>1 and 4-8</u> is/are allowed. | | | | | | | |
| 6)⊠ Claiı | Claim(s) <u>2 and 3</u> is/are rejected. | | | | | | | |
| 7)∐ Claiı | Claim(s) is/are objected to. | | | | | | | |
| 8)∏ Claii | Claim(s) are subject to restriction and/or election requirement. | | | | | | | |
| Application P | apers | | | | | | | |
| , - | specification is objected to by th | | | | | | | |
| 10)⊠ The drawing(s) filed on <u>30 December 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner. | | | | | | | | |
| • • | Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). | | | | | | | |
| • | Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). | | | | | | | |
| 11) | oath or declaration is objected t | to by the Examiner. N | ote the attached Office | Action or form P1 | √O-152. | | | |
| Priority unde | r 35 U.S.C. § 119 | | | | | | | |
| a)⊠ Al | owledgment is made of a claim b) Some * c) None of: | | • |)-(d) or (f). | | | | |
| 1.⊠ | | | | ion No | | | | |
| 2 | Certified copies of the priority Copies of the certified copies | | | | Stane | | | |
| ა.∟ | application from the Internati | | | | Otage | | | |
| * See ti | he attached detailed Office acti | | | ed. | | | | |
| | | | • | | | | | |
| Attachment(s) | | | | | | | | |
| | eferences Cited (PTO-892) | | 4) Interview Summary | | | | | |
| | raftsperson's Patent Drawing Review (Disclosure Statement(s) (PTO-1449 o | | Paper No(s)/Mail Date 5) Notice of Informal F | | O-152) | | | |
| | s)/Mail Date | | 6) Other: | • | | | | |

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Application No: 10/749,489

Docket: 20063/10020

Seung-Hee JWA

OFFICE ACTION

Specification

1. The specification is objected to because of the following informality: Paragraph 0007, line 1, replace "Figs. 1 and 2" with --Figs. 1 through 3--

Drawings

2. Figures 1-3 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). Corrected drawings in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application.

Claim Rejections - 35 U.S.C. § 112

3. Claims 2 and 3 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Examiner notes that paragraph 0015 disclosing "the first polysilicon layer may be between 300Å and 2500Å thicker than the device isolation layer" is different than paragraph 0028 disclosing "the first polysilicon layer may be 300Å-2500Å thicker than the first trench." Paragraph 0028 supports claims 2-3. However, paragraph 0015 and the application's figures supports "0the first polysilicon layer 44 formed more thickly than the device isolation layer 52" because trench T1 itself is a lot thicker than the polySi layer 44. Please clarify the subject matter of claims 2 and 3

Allowable Subject Matter

4. Claims 1 and 4-8 are allowed. Following is the statement reason for allowance:

The closest prior art, US 6,724,036 to *Hsieh et al* discloses features of the invention except for the teaching of "forming a first trench on the exposed part of the substrate and a second trench on the exposed part of the floating gate."

Any inquiry concerning this communication from the Examiner should be directed to *Calvin Lee* at (571) 272-1896 from 7:00AM to 5:00PM (Monday-Thursday, Eastern Time). If attempts to reach the examiner by telephone are unsuccessful, Art Unit 2825's Supervisory Patent Examiner *David C. Nelms* can be reached at (571) 272-1787. Any inquiry relating to the status of this application should be directed to the Group receptionist whose telephone number is (703) 308-0596. The central fax number is (703) 872-9306 for all communications to be entered (e.g., amendments, remarks, IDS, etc.)

February 2, 2005